

FORM PTO-1449 U.S. Department of Commerce  
(Rev. 4/92) Patent and Trademark Office

ATTY. DOCKET NO.  
APV31121

SERIAL NO.  
09/702,084

INFORMATION DISCLOSURE  
STATEMENT BY APPLICANT

(Use several sheets if necessary)

APPLICANT  
Sivik et al.

FILING DATE  
October 30, 2000

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U.S. PATENT DOCUMENTS

EXAMINER INITIAL	DOCUMENT NUMBER	DATE	NAME	CLASS	SUBCLASS	FILING DATE IF APPROPRIATE
PN	5 7 8 3 5 3 3	07/98	Kensicher			
	4 4 5 4 0 6 0	06/84	Lai et al.			
	5 8 5 3 7 1 0	12/98	Dehan et al.			
	5 8 5 8 3 4 3	01/99	Szymczak			
	5 8 8 2 5 4 1	03/99	Achtmann			
	5 9 0 2 5 7 4	05/99	Stoner et al.			
PN	5 9 0 2 7 7 8	05/99	Hartmann et al.			

FOREIGN PATENT DOCUMENTS

	DOCUMENT NUMBER	DATE	COUNTRY	CLASS	SUBCLASS	TRANSLATION	
						YES	NO
PN	5 6 0 5 6 7	09/93	EP				
	9 5 2 2 3 1 1	08/95	WO				
	9 7 2 9 7 3 6	08/97	WO				
	9 7 3 5 5 4 9	10/97	WO				
	9 9 1 5 3 2 1	06/99	AU				
	9 9 1 5 3 2 2	06/99	AU				
	0 3 0 8 1 9 0	03/89	EP				
	0 0 0 6 1 0 2	02/00	WO				
	9 8 3 8 9 7 3	09/98	WO				
PN	9 8 3 9 4 0 1	09/98	WO				

OTHER DOCUMENTS (Including Author, Title, Date, Pertinent Pages, Etc.)

PN	US Patent Application No. 09/698,479 filed October 30, 2000 in the name of Yeung et al.
PN	US Patent Application No. 09/698,149 filed October 30, 2000 in the name of Yeung et al.

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EXAMINER INITIAL	DOCUMENT NUMBER	DATE	NAME	CLASS	SUBCLASS	FILING DATE IF APPROPRIATE
PM	5 7 1 4 0 0 1	02/98	Savoly et al.			
	5 2 7 7 8 9 9	01/94	McCall			
	3 0 9 9 6 3 6	07/63	Skiles			
	4 3 0 4 7 0 3	12/81	Das			
	4 4 8 6 4 8 9	12/84	George			
	3 2 4 9 4 5 5	05/66	Williams			
	3 6 7 1 5 0 2	06/72	Samour et al.			
	4 5 2 8 1 1 1	07/85	Su			
	5 3 3 8 5 4 1	08/94	Matz et al.			
	5 5 8 0 8 1 9	12/96	Li et al.			
PM	4 8 3 5 2 1 1	05/89	Noda et al.			

## FOREIGN PATENT DOCUMENTS

	DOCUMENT NUMBER	DATE	COUNTRY	CLASS	SUBCLASS	TRANSLATION	
						YES	NO
PM	1 0 7 3 9 4 7	06/67	GB				
↓	9 1 1 5 5 2 4	10/91	WO				
↓	9 8 0 1 4 7 8	01/98	WO				
PM	5 3 1 1 1 9 4	11/93	JP			Abstract Only	

## OTHER DOCUMENTS (Including Author, Title, Date, Pertinent Pages, Etc.)


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P/L	3 9 6 0 7 6 3	06-76	Lambou et al	1		
	4 7 1 3 1 8 2	12-87	Hiltz et al			
	4 7 3 4 0 9 9	03-88	Cyprien			
	5 0 2 7 8 9 8	07-91	Naae			
	5 0 4 2 5 8 3	08-91	D'Souza et al			
	5 1 0 4 6 4 3	04-92	Grollier et al			
	5 1 6 9 4 4 1	12-92	Lauzon			
	5 2 1 8 0 2 1	06-93	Clark et al			
	5 2 3 2 6 3 2	08-93	Woo et al			
	5 3 4 6 6 9 9	09-94	Tierman et al			
	5 4 1 5 8 6 0	05-95	Beucherie et al			
	5 4 9 6 4 7 5	03-96	Jho et al			
	5 5 3 6 4 5 2	07-96	Black			
	5 5 4 9 8 6 9	08-96	Iwakawa			
	5 5 8 7 0 2 2	12-96	Black			
	5 6 1 2 3 0 8	03-97	Woo et al			
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	5 7 0 6 8 9 5	01-98	Sydansk			
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	5 8 2 1 2 0 3	10-98	Williamson			
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